



**Volume 74 (2018)**

**Supporting information for article:**

**Thermal stability of the layered modification of  $\text{Cu}_{0.5}\text{ZrTe}_2$  in the temperature range 25–900 °C**

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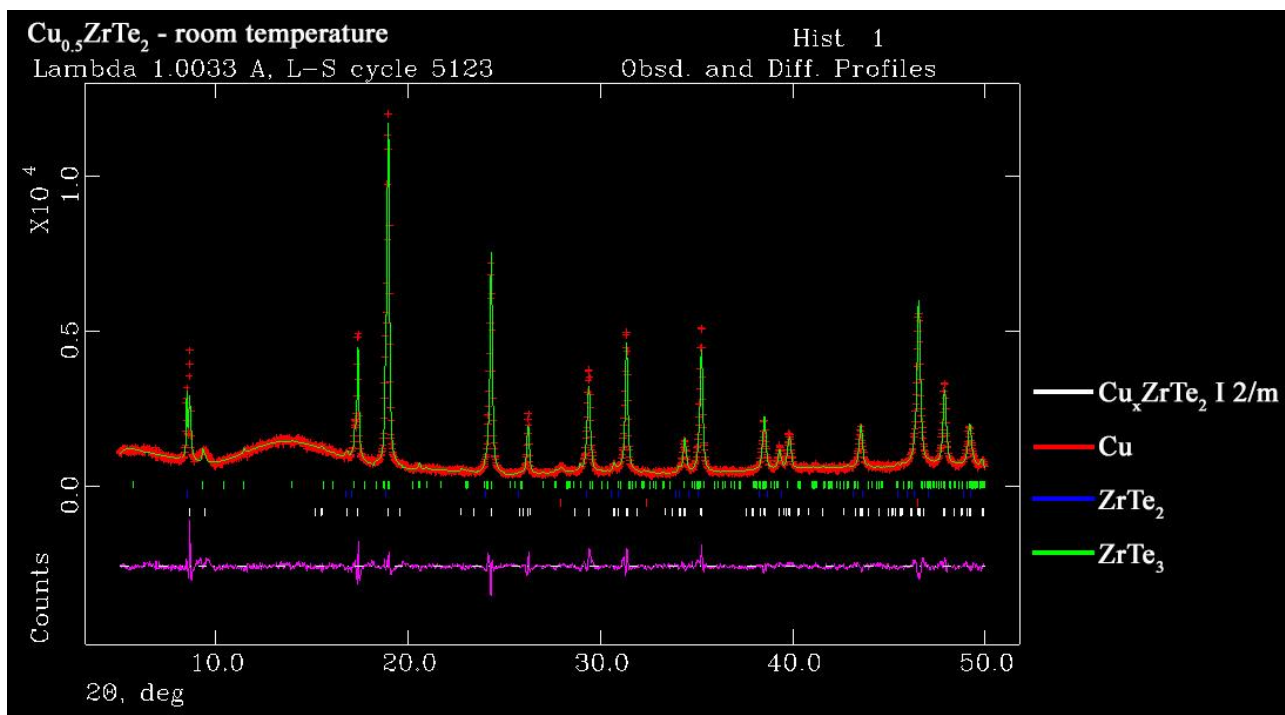


Fig. S1

The experimental (green line) and calculated (red cross) X-ray diffraction patterns for  $\text{Cu}_{0.5}\text{ZrTe}_2$  (RT). As purple line are shown the difference curves between calculated and observed profiles. As colored tick are shown the contributions of the corresponding phases.

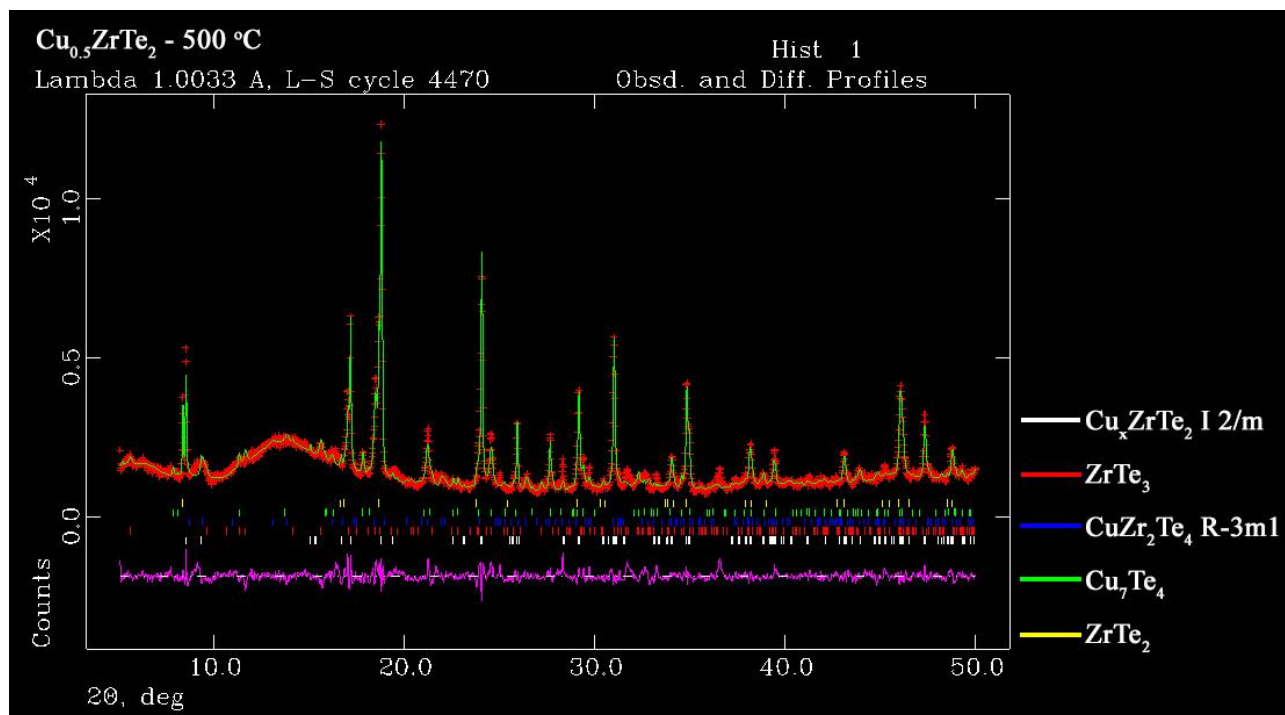


Fig. S2

The experimental (green line) and calculated (red cross) X-ray diffraction patterns for  $\text{Cu}_{0.5}\text{ZrTe}_2$  (500 C). As purple line are shown the difference curves between calculated and observed profiles. As colored tick are shown the contributions of the corresponding phases.

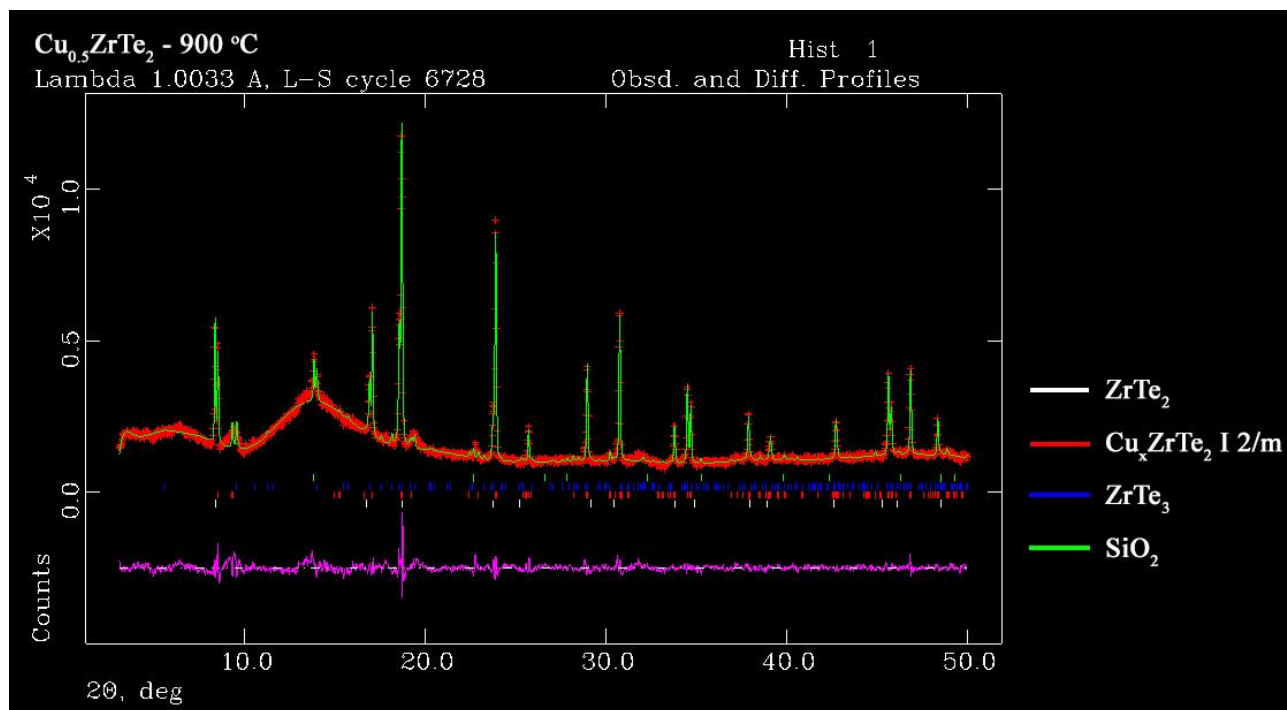


Fig. S3

The experimental (green line) and calculated (red cross) X-ray diffraction patterns for  $\text{Cu}_{0.5}\text{ZrTe}_2$  ( $900\text{ }^\circ\text{C}$ ). As purple line are shown the difference curves between calculated and observed profiles. As colored tick are shown the contributions of the corresponding phases.

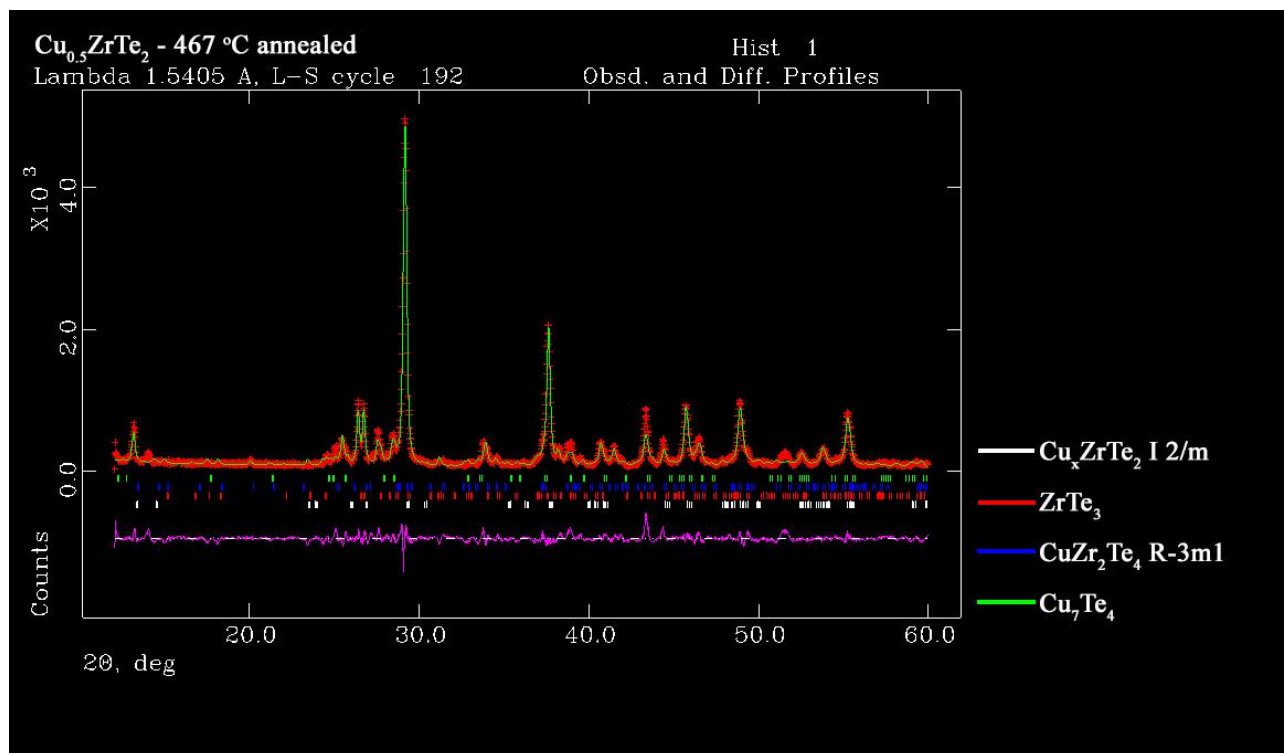


Fig. S4

The experimental (green line) and calculated (red cross) X-ray diffraction patterns for  $\text{Cu}_{0.5}\text{ZrTe}_2$  (467 °C annealed). As purple line are shown the difference curves between calculated and observed profiles. As colored tick are shown the contributions of the corresponding phases.